Supply Chain Explorer

By the Emerging Technology Observatory

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Chemical mechanical planarization materials

The highest-value materials used in chemical mechanical planarization are chemical slurries, which often include rare earth minerals, and polishing pads. During fabrication, a wafer is placed on the pad along with the slurry, and a polishing head presses against the wafer and rotates to planarize the wafer.

Country provision

- · China (mainland)
- France
- Japan
- · United States

Notable supplier companies

- · Anji China (mainland)
- · CMC United States
- DuPont United States
- · Fujifilm Electronic Materials Japan
- Fujimi Japan
- · Hitachi Japan
- Hubei Dinglong China (mainland)
- JSR Japan
- · Merck Group Germany
- Pureon United States
- Saint-Gobain France
- Thomas West United States
- · Versum Materials United States